

Chromium **CARBIDE** Sputtering Target

NS6130-10-1258

Quick Facts

Product	:	Sputtering Target Chromium Carbide
Stock No	:	NS6130-10-1258
CAS	:	12012-35-0
Molecular Formula	:	Cr ₃ C ₂
Form	:	Solid

Technical Specification

Diameter	Thickness	Purity
50.8 mm ± 1mm	3 mm ± 0.5mm	99.99%

Chromium carbide sputtering target is used for thin film deposition, decoration, semiconductor, display, LED and photovoltaic devices, electronics and information industry, glass coating field, wear-resistant materials, high-temperature corrosion resistance, high-grade decorative goods, and other industries, functional coating as nicely as other optical information storage space industry, glass coating industry like car glass and architectural glass, optical communication, etc.



* This image is for graphic purposes only and does not represent the actual product.

